## IN THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

1-41.(Canceled)

42. (Currently Amended) A display device comprising:

a semiconductor substrate;

an insulating layer formed on the semiconductor substrate;

a switching transistor and a current controlling transistor formed on the insulating layer, each comprising a source region, a drain region, a gate electrode and a gate insulating film;

a first interlayer insulating film over the switching transistor and the current controlling transistor;

a source wiring and a drain wiring which are connected with the switching transistor and a source wiring and a drain wiring which are connected with the current controlling transistor, and formed over the first interlayer insulating film;

[[an]] <u>a second</u> interlayer insulating film formed over <u>the source wiring and the drain wiring</u>
of the switching transistor and <u>the source wiring and the drain wiring of</u> the current controlling transistor;

an electrode electrically connected with one of the source region wiring and the drain region wiring of the switching transistor, and formed over the second interlayer insulating film;

a dielectric layer formed on the electrode;

a power supply line electrically connected with one of the source region wiring and the drain

region wiring of the current controlling transistor, and formed on the dielectric layer;

a first electrode electrically connected with the other one of the source region wiring and the drain region wiring of the current controlling transistor;

an EL layer formed over the first electrode; and a second electrode formed over the EL layer.

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43.(Previously Presented) A display device according to claim 42, wherein the display device is incorporated in at least one selected from the group consisting of a portable telephone, a video camera, a mobile computer, a goggle type display, a projector, an electronic book, a digital camera, and a DVD player.

244. (Previously Presented) A display device according to claim 42, wherein the first electrode overlaps the power supply line.

45. (Previously Presented) A display device according to claim 42, wherein the electrode comprises one selected from the group consisting of Al, Ta and Ti.

46. (Previously Presented) A display device according to claim \$2, wherein the dielectric layer comprises an oxidation film of the electrode.

97.(Currently Amended) A display device comprising:

a semiconductor substrate;

an insulating layer formed on the semiconductor substrate;

a p-channel type switching transistor and an n-channel type current controlling transistor formed on the insulating layer, each comprising a source region, a drain region, a gate electrode and a gate insulating film;

a first interlayer insulating film over the p-channel type switching transistor and the n-channel type current controlling transistor;

a source wiring and a drain wiring which are connected with the p-channel type switching transistor and a source wiring and a drain wiring which are connected with the n-channel type current controlling transistor, and formed over the first interlayer insulating film;

[[an]] <u>a second</u> interlayer insulating film formed over <u>the source wiring and the drain wiring</u>
of the p-channel type switching transistor and <u>the source wiring and the drain wiring of</u> the n-channel
type current controlling transistor;

an electrode electrically connected with one of the source region wiring and the drain region wiring of the p-channel type switching transistor, and formed over the second interlayer insulating film;

a dielectric layer formed on the electrode;

a power supply line electrically connected with one of the source region wiring and the drain region wiring of the n-channel type current controlling transistor, and formed on the dielectric layer;

a first electrode electrically connected with the other one of the source region wiring and the drain region wiring of the n-channel type current controlling transistor;

an EL layer formed over the first electrode; and

a second electrode formed over the EL layer.

48. (Previously Presented) A display device according to claim 41, wherein the first electrode overlaps the power supply line.

(Previously Presented) A display device according to claim 1, wherein the electrode comprises one selected from the group consisting of Al, Ta and Ti.

(b)
(Previously Presented) A display device according to claim 47, wherein the dielectric layer comprises an oxidation film of the electrode.

is incorporated in at least one selected from the group consisting of a portable telephone, a video camera, a mobile computer, a goggle type display, a projector, an electronic book, a digital camera, and a DVD player.

52.(Currently Amended) A display device comprising:

a semiconductor substrate;

a switching transistor and a current controlling transistor formed on the semiconductor substrate, each comprising a source region, a drain region, a gate electrode and a gate insulating film;

a first interlayer insulating film over the switching transistor and the current controlling transistor;

a source wiring and a drain wiring which are connected with the switching transistor and a

source wiring and a drain wiring which are connected with the current controlling transistor, and formed over the first interlayer insulating film;

[[an]] <u>a second</u> interlayer insulating film formed over <u>the source wiring and the drain wiring</u>
of the switching transistor and <u>the source wiring and the drain wiring of</u> the current controlling transistor;

an electrode electrically connected with one of the source region wiring and the drain region wiring of the switching transistor, and formed over the second interlayer insulating film;

a dielectric layer formed on the electrode;

a power supply line electrically connected with one of the source region wiring and the drain region wiring of the current controlling transistor, and formed on the dielectric layer;

a first electrode electrically connected with the other one of the source region wiring and the drain region wiring of the current controlling transistor;

an EL layer formed over the first electrode; and a second electrode formed over the EL layer.

52. (Previously Presented) A display device according to claim 52, wherein the first electrode overlaps the power supply line.

(Previously Presented) A display device according to claim 52, wherein the electrode comprises one selected from the group consisting of Al, Ta and Ti.

(Previously Presented) A display device according to claim \$2, wherein the dielectric layer comprises an oxidation film of the electrode.

(Previously Presented) A display device according to claim 52, wherein the display device is incorporated in at least one selected from the group consisting of a portable telephone, a video camera, a mobile computer, a goggle type display, a projector, an electronic book, a digital camera, and a DVD player.

81. (Currently Amended) A display device comprising:

a semiconductor substrate;

a p-channel type switching transistor and an n-channel type current controlling transistor formed on the semiconductor substrate, each comprising a source region, a drain region, a gate electrode and a gate insulating film;

a first interlayer insulating film over the p-channel type switching transistor and the n-channel type current controlling transistor;

a source wiring and a drain wiring which are connected with the p-channel type switching transistor and a source wiring and a drain wiring which are connected with the n-channel type current controlling transistor, and formed over the first interlayer insulating film;

[[an]] <u>a second</u> interlayer insulating film formed over <u>the source wiring and the drain wiring</u>
of the p-channel type switching transistor and <u>the source wiring and the drain wiring of</u> the n-channel
type current controlling transistor;

an electrode electrically connected with one of the source region wiring and the drain region

wiring of the p-channel type switching transistor, and formed over the <u>second</u> interlayer insulating film;

a dielectric layer formed on the electrode;

a power supply line electrically connected with one of the source region wiring and the drain region wiring of the n-channel type current controlling transistor, and formed on the dielectric layer;

a first electrode electrically connected with the other one of the source region wiring and the drain region wiring of the n-channel type current controlling transistor;

an EL layer formed over the first electrode; and

a second electrode formed over the EL layer.

58. (Previously Presented) A display device according to claim 51, wherein the first electrode overlaps the power supply line.

(Previously Presented) A display device according to claim 57, wherein the electrode comprises one selected from the group consisting of Al, Ta and Ti.

(9)
(Previously Presented) A display device according to claim 57, wherein the dielectric layer comprises an oxidation film of the electrode.

(A) (Previously Presented) A display device according to claim 57, wherein the display device is incorporated in at least one selected from the group consisting of a portable telephone, a video camera, a mobile computer, a goggle type display, a projector, an electronic book, a digital camera, and a DVD player.

62.(Currently Amended) A display device comprising:

a semiconductor substrate;

a switching transistor and a current controlling transistor formed on the semiconductor substrate, each comprising a source region, a drain region, a gate electrode and a gate insulating film;

a first interlayer insulating film over the switching transistor and the current controlling transistor;

a source wiring and a drain wiring which are connected with the switching transistor and a source wiring and a drain wiring which are connected with the current controlling transistor, and formed over the first interlayer insulating film;

[[an]] <u>a second</u> interlayer insulating film formed over <u>the source wiring and the drain wiring</u>
of the switching transistor and <u>the source wiring and the drain wiring of</u> the current controlling transistor;

an electrode electrically connected with one of the source region wiring and the drain region wiring of the switching transistor, and formed over the second interlayer insulating film;

a dielectric layer formed on the electrode;

a power supply line electrically connected with one of the source region wiring and the drain region wiring of the current controlling transistor, and formed on the dielectric layer;

a storage capacitance comprising the electrode, the dielectric layer and the power supply line;
a first electrode electrically connected with the other one of the source region wiring and the
drain region wiring of the current controlling transistor;

an EL layer formed over the first electrode; and a second electrode formed over the EL layer.

Overlaps the power supply line.

2)
64.(Previously Presented) A display device according to claim 62, wherein the electrode comprises one selected from the group consisting of Al, Ta and Ti.

(Previously Presented) A display device according to claim 62, wherein the dielectric layer comprises an oxidation film of the electrode.

66. (Previously Presented) A display device according to claim 62, wherein the display device is incorporated in at least one selected from the group consisting of a portable telephone, a video camera, a mobile computer, a goggle type display, a projector, an electronic book, a digital camera, and a DVD player.

3 | 61.(Currently Amended) A display device comprising:

a semiconductor substrate;

a p-channel type switching transistor and an n-channel type current controlling transistor formed on the semiconductor substrate, each comprising a source region, a drain region, a gate electrode and a gate insulating film;

a first interlayer insulating film over the p-channel type switching transistor and the n-channel type current controlling transistor;

a source wiring and a drain wiring which are connected with the p-channel type switching transistor and a source wiring and a drain wiring which are connected with the n-channel type current controlling transistor, and formed over the first interlayer insulating film;

[[an]] <u>a second</u> interlayer insulating film formed over <u>the source wiring and the drain wiring</u>
of the p-channel type switching transistor and <u>the source wiring and the drain wiring of</u> the n-channel
type current controlling transistor;

an electrode electrically connected with one of the source region wiring and the drain region wiring of the p-channel type switching transistor, and formed over the second interlayer insulating film;

a dielectric layer formed on the electrode;

a power supply line electrically connected with one of the source region wiring and the drain region wiring of the n-channel type current controlling transistor, and formed on the dielectric layer; a storage capacitance comprising the electrode, the dielectric layer and the power supply line; a first electrode electrically connected with the other one of the source region wiring and the drain region wiring of the n-channel type current controlling transistor;

an EL layer formed over the first electrode; and a second electrode formed over the EL layer.

(Previously Presented) A display device according to claim 67, wherein the first electrode overlaps the power supply line.

(Previously Presented) A display device according to claim 61, wherein the electrode comprises one selected from the group consisting of Al, Ta and Ti.

70. (Previously Presented) A display device according to claim 67, wherein the dielectric layer comprises an oxidation film of the electrode.

37. (Previously Presented) A display device according to claim 67, wherein the display device is incorporated in at least one selected from the group consisting of a portable telephone, a video camera, a mobile computer, a goggle type display, a projector, an electronic book, a digital camera, and a DVD player.

72. (Previously Presented) A display device according to claim 42, wherein the EL layer is organic.

73.(Previously Presented) A display device according to claim 47, wherein the EL layer is organic.

74. (Previously Presented) A display device according to claim 52, wherein the EL layer is organic.

78. (Previously Presented) A display device according to claim 57, wherein the EL layer is organic.

76. (Previously Presented) A display device according to claim 62, wherein the EL layer is organic.

71. (Previously Presented) A display device according to claim 67, wherein the EL layer is organic.